

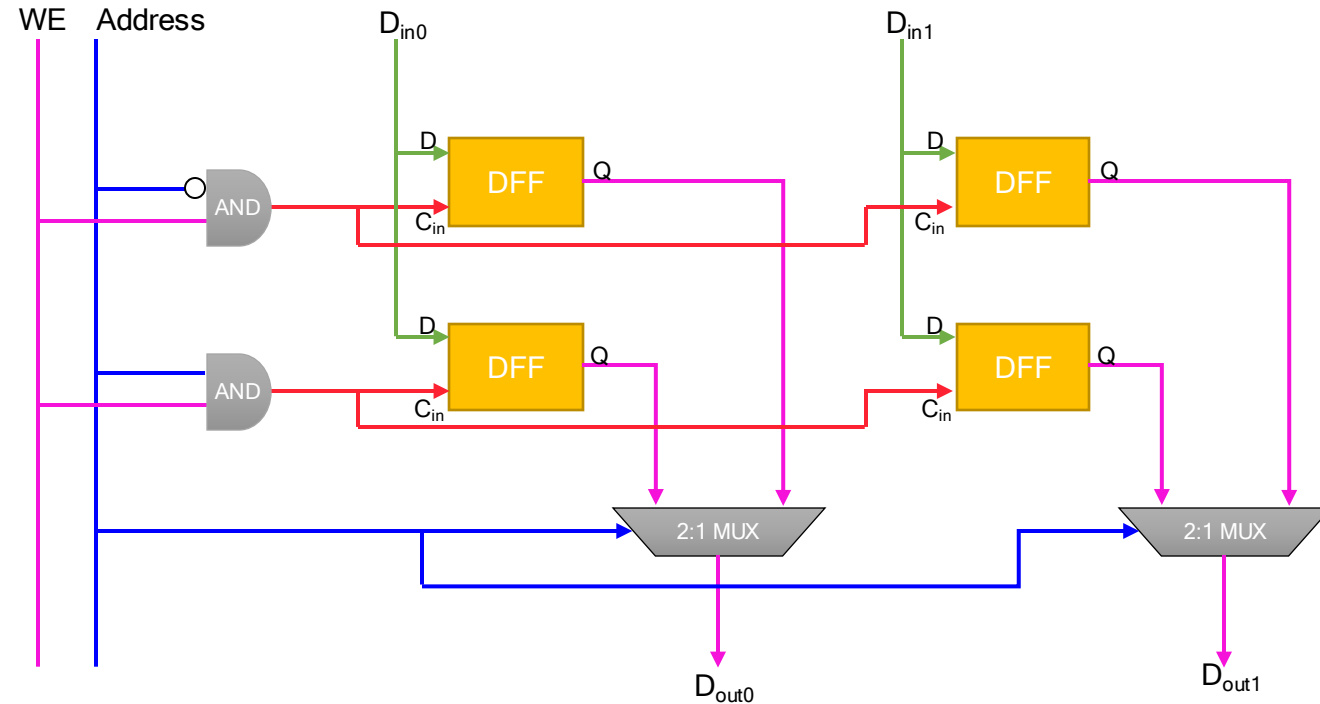
Memory Technologies

Memory Hierarchy

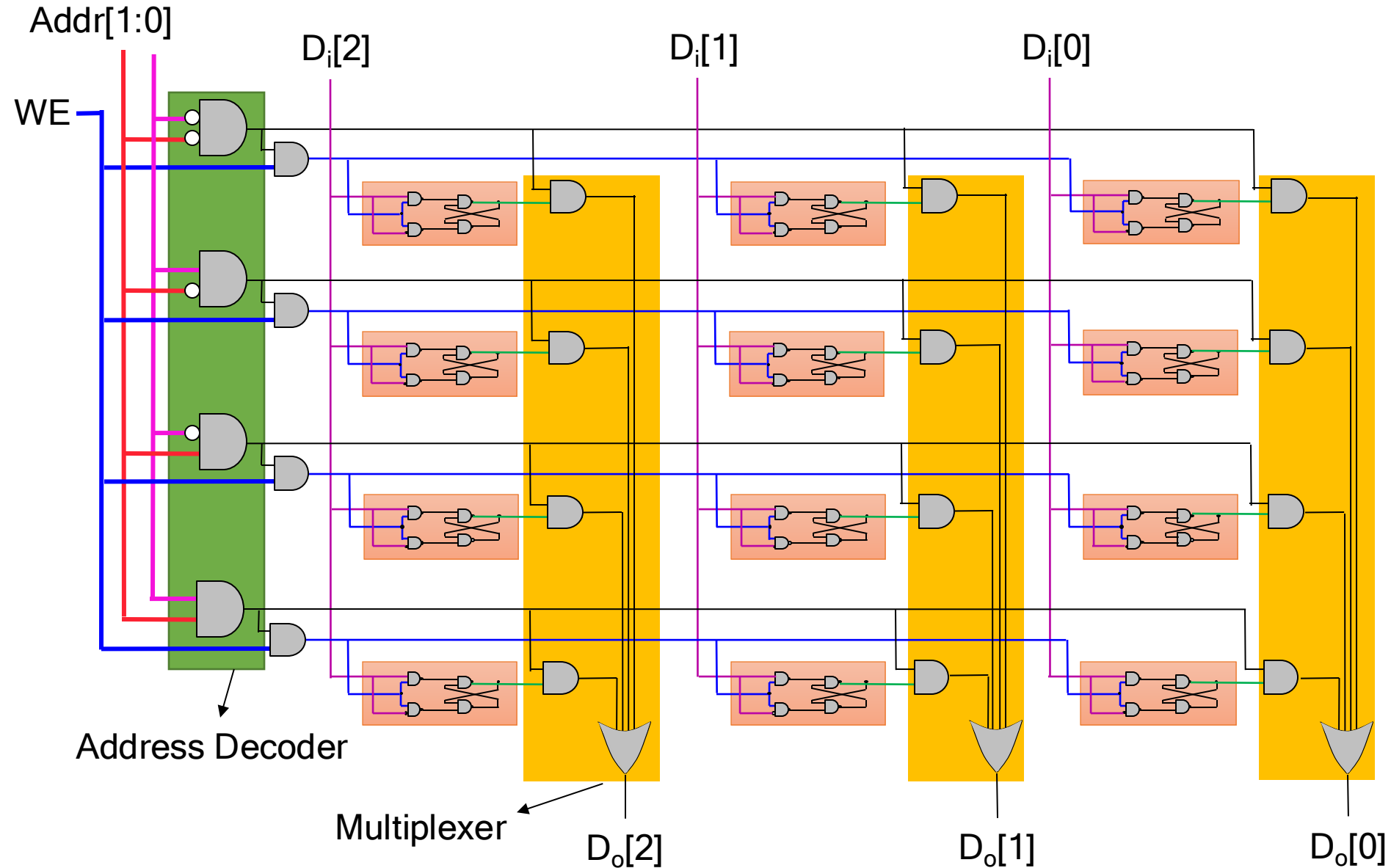
- Registers - Flip Flops (D flip flop)
- L1, L2 Cache - SRAM
- L3 Cache - eDRAM
- Main memory - DDR
- Secondary memory - Flash, Magnetic disk, etc

Two 2Bit Register Design

- Write will be allowed only when clock input is activated
- Clock input must be activated only when WE signal is asserted
- 1:2 Decoder is used to decode the address lines
- 2:1 Multiplexer is used to select one 1 out of 2

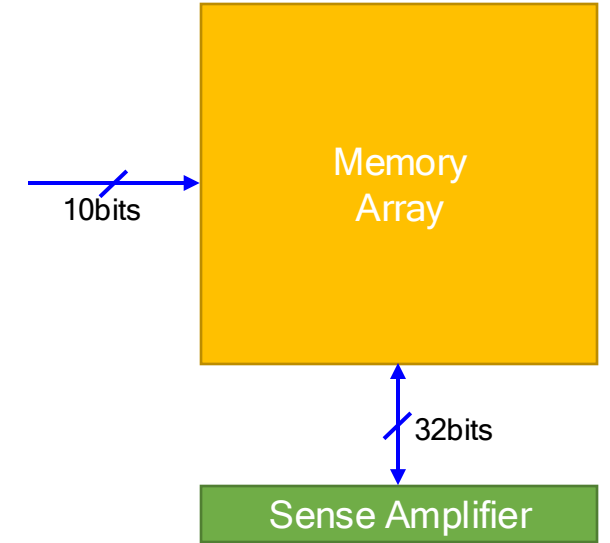


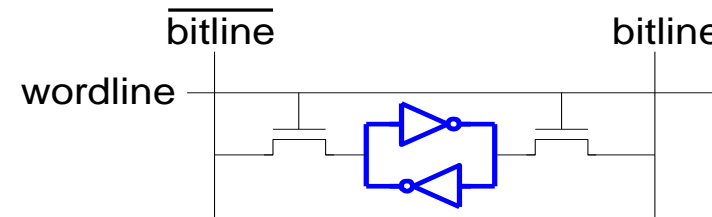
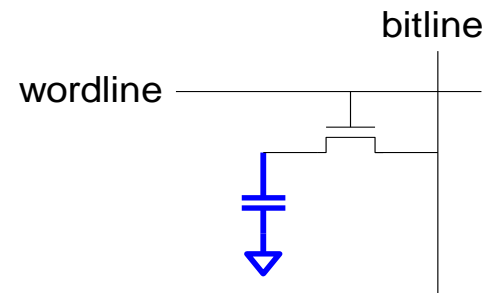
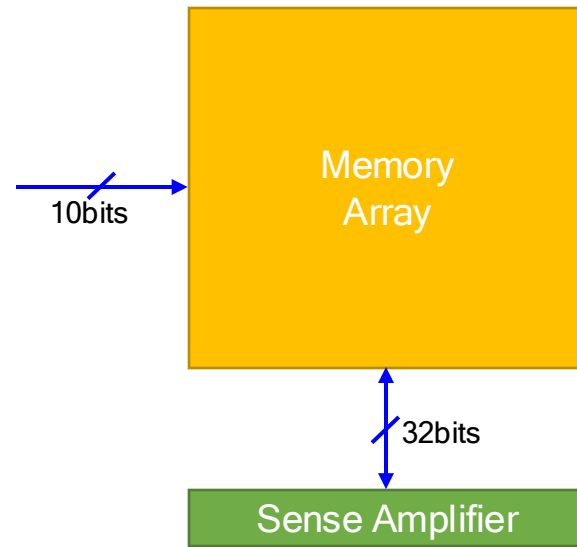
Four 3Bit Register Design



Problems with single larger memory array

- Reads and Writes are done in the granularity of row size, here row size is too big
 - Think about you want to write 32bit data

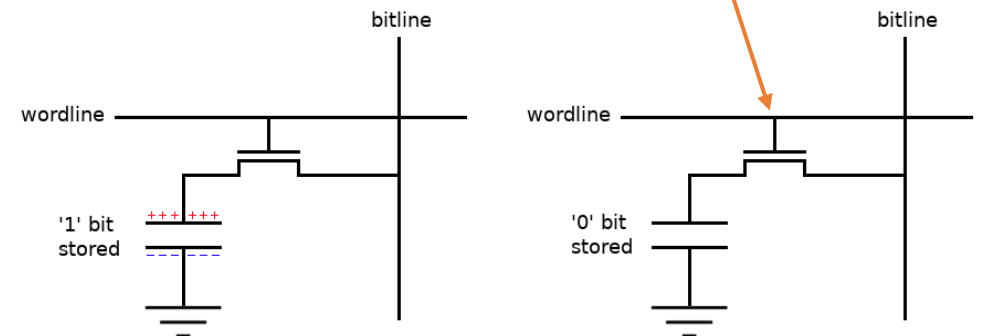


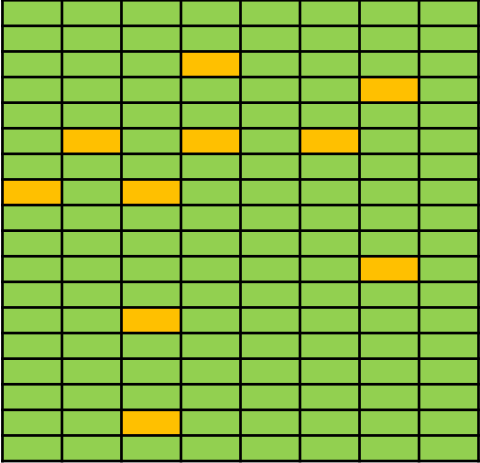


DRAM

DRAM Basics

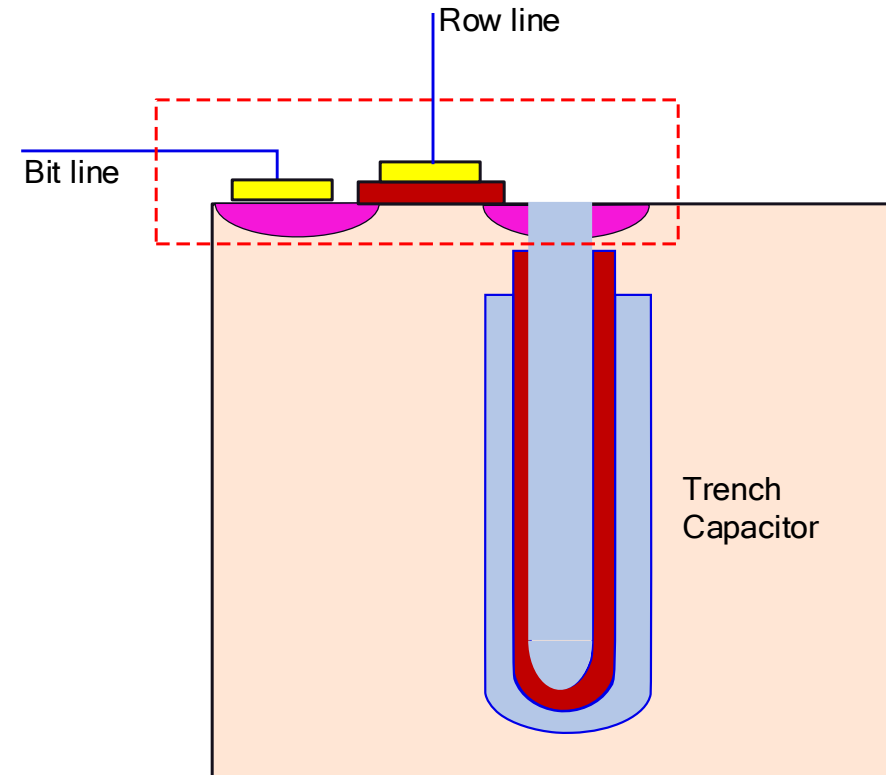
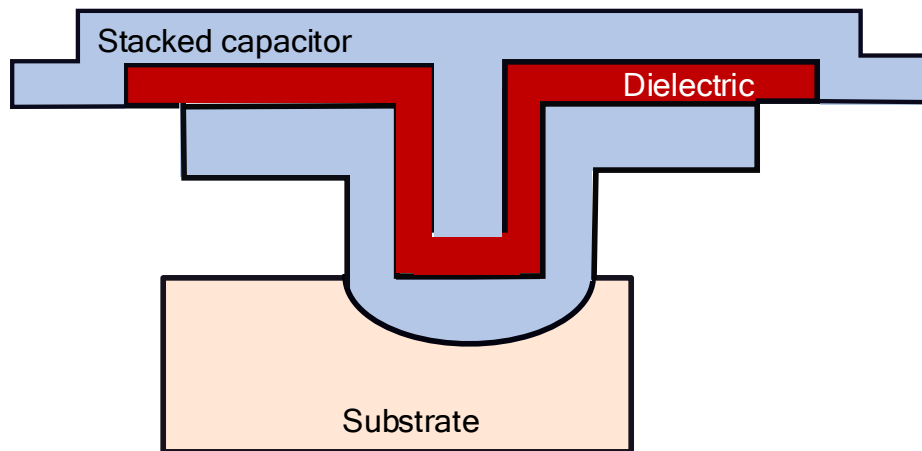
- DRAM cell is composed of a **capacitor** and a **transistor**
- Data (0 or 1) is stored in the capacitor
- Writing data is very simple just drive the bit line 😊
- Reading data is complex. After turning the access transistor ON, the bit line gets charged or discharged
 - The cell loses its value → Destructive 💀
- The data in the capacitor is always read out and then write back at later time (**Precharge**)
- Capacitors can loose charge over the time which leads to explicit **refreshing** (~64ns)
 - Pass transistor is not an perfect switch, hence leakage current can flow through it either from bit line to capacitor or vice versa
 - If dielectric material between the capacitor plate is not perfect then it may leads to allow some leakage current
 - Higher temperature may accelerate the movement of charge carriers through dielectric
 - Process variability
 - Aging
- Capacitor only takes few Nano seconds to fully charge up → 30femto (10^{-15})





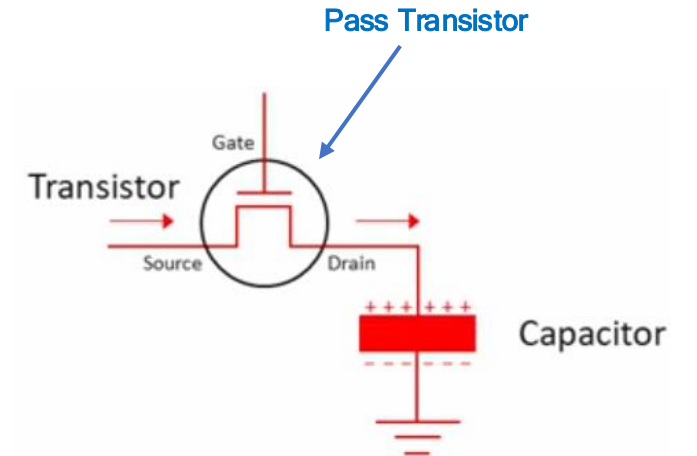
DRAM Cell Capacitors

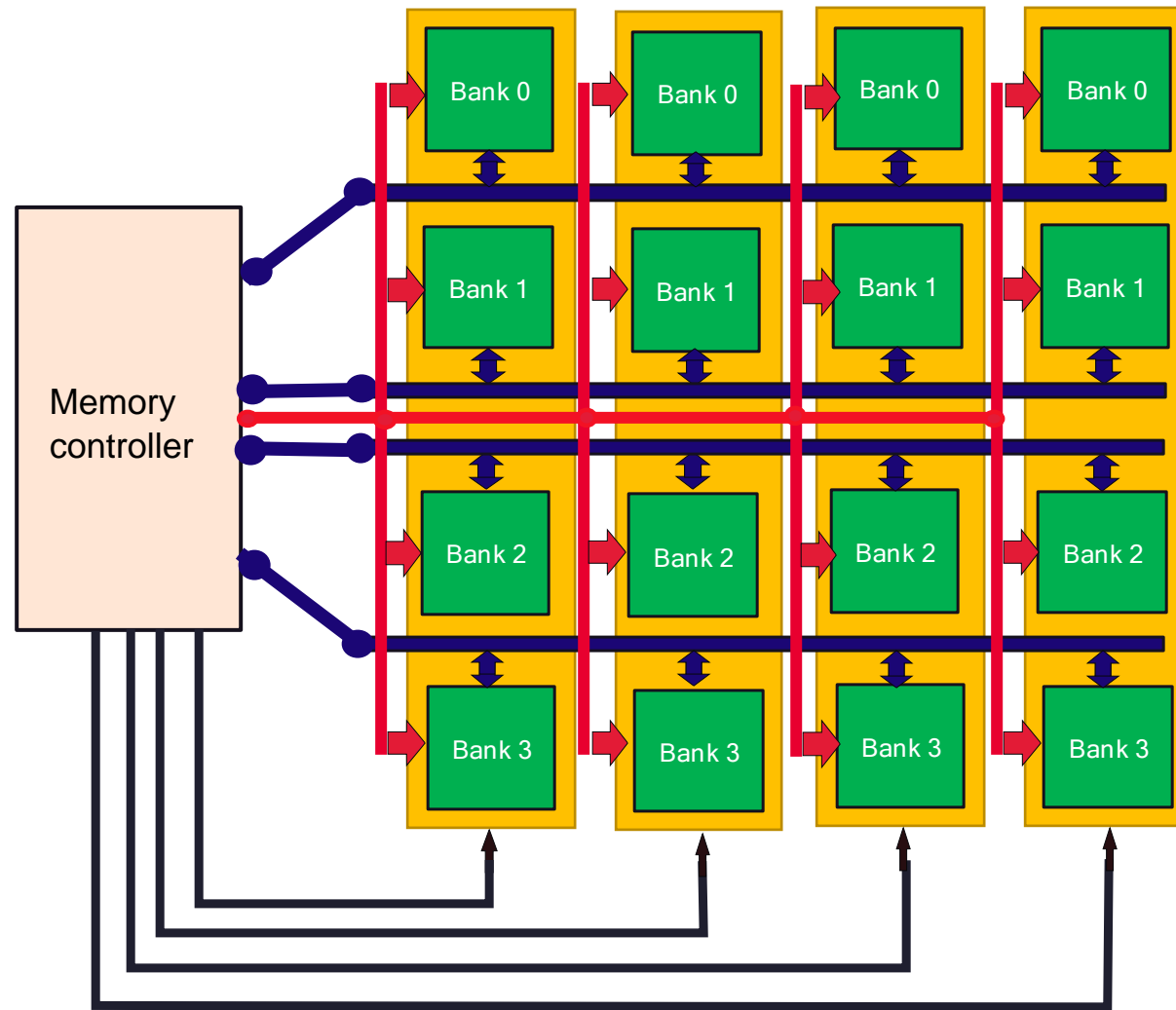
- Capacitance $C = \frac{EA}{D}$
 - $E \rightarrow$ Permittivity of the dielectric material
 - $A \rightarrow$ Area of the plates
 - $D \rightarrow$ Distance between the plates
- Two methods of capacitor fabrication
 - Trench capacitor
 - Stacked capacitor



DRAM Scaling Problems

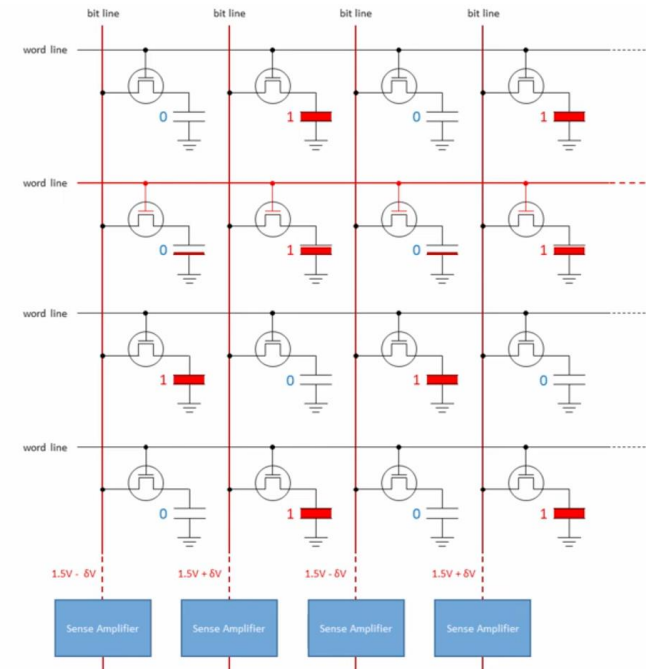
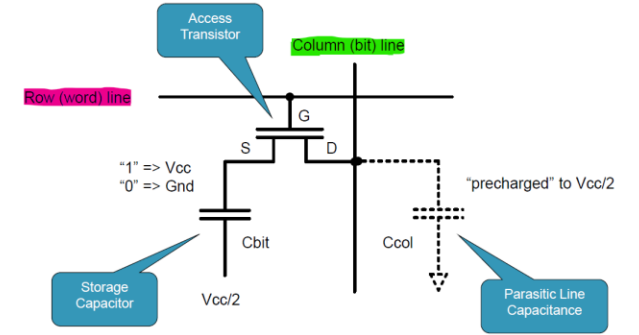
- DRAM stores charge in a capacitor (Charge based memory)
 - Cell Capacitor must be large enough for reliable sensing at bit line (**Problem** - Memory density reduces)
 - Access transistor must be large enough for reliable sensing
- Scaling beyond 17nm is challenging
- Refresh retention time prediction is challenging





DRAM - Read Write operation

- Bit line is precharged to sense amplifier threshold voltage $V_{DD}/2$
- Row address strobe signal gets asserted
- If bit line capacitor is charged
 - Bit line voltage gets increased by $V_{DD}/2 + \beta$ and cell voltage gets reduced by $V_{DD}/2 - \beta$
- If bit line capacitor is not charged
 - Bit line voltage gets increased by $V_{DD}/2 - \beta$ and cell voltage gets reduced by $V_{DD}/2 + \beta$
- Sense amplifier senses the voltage difference at the bit line with respect to the Original voltage and accordingly latched the data in to the row buffer
- Increase or decrease the voltage of the bit line by β according to the row buffer Value which will increase or decrease the voltage of the cell capacitor

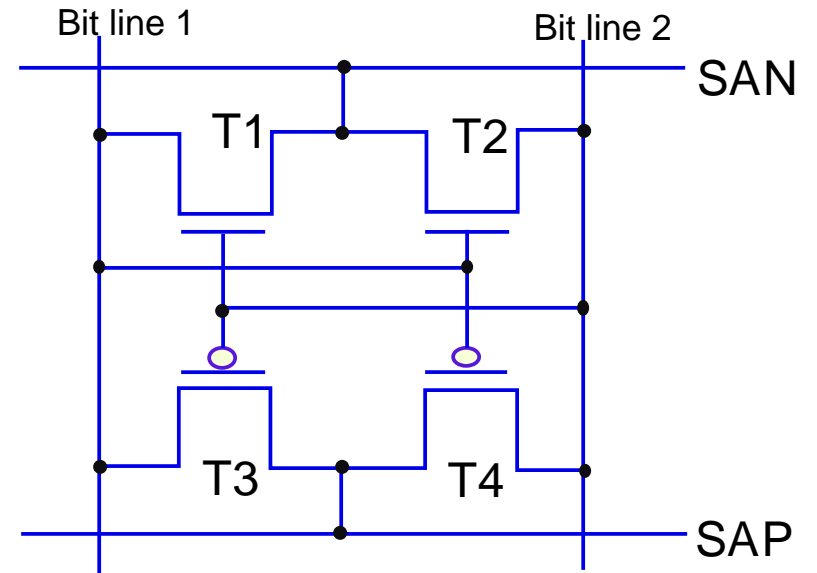
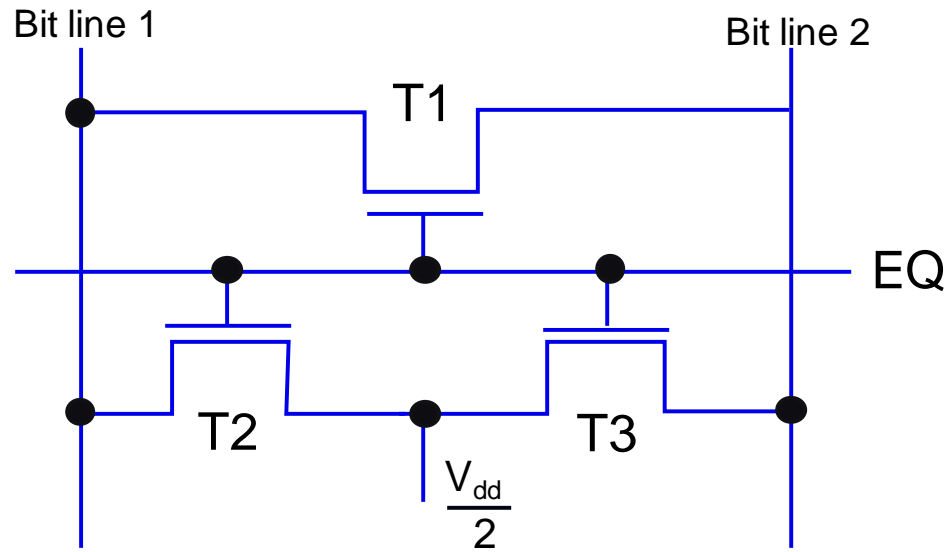


DRAM Basics - How to increase the speed of the chip

- Split the single big array of memory cells into multiple banks
- This allows more banks to be active at the same time
- This can effectively hide the activate/precharge and other timing related to single bank implementations
- Refresh timing is not affected since all the banks are refreshed at the same time

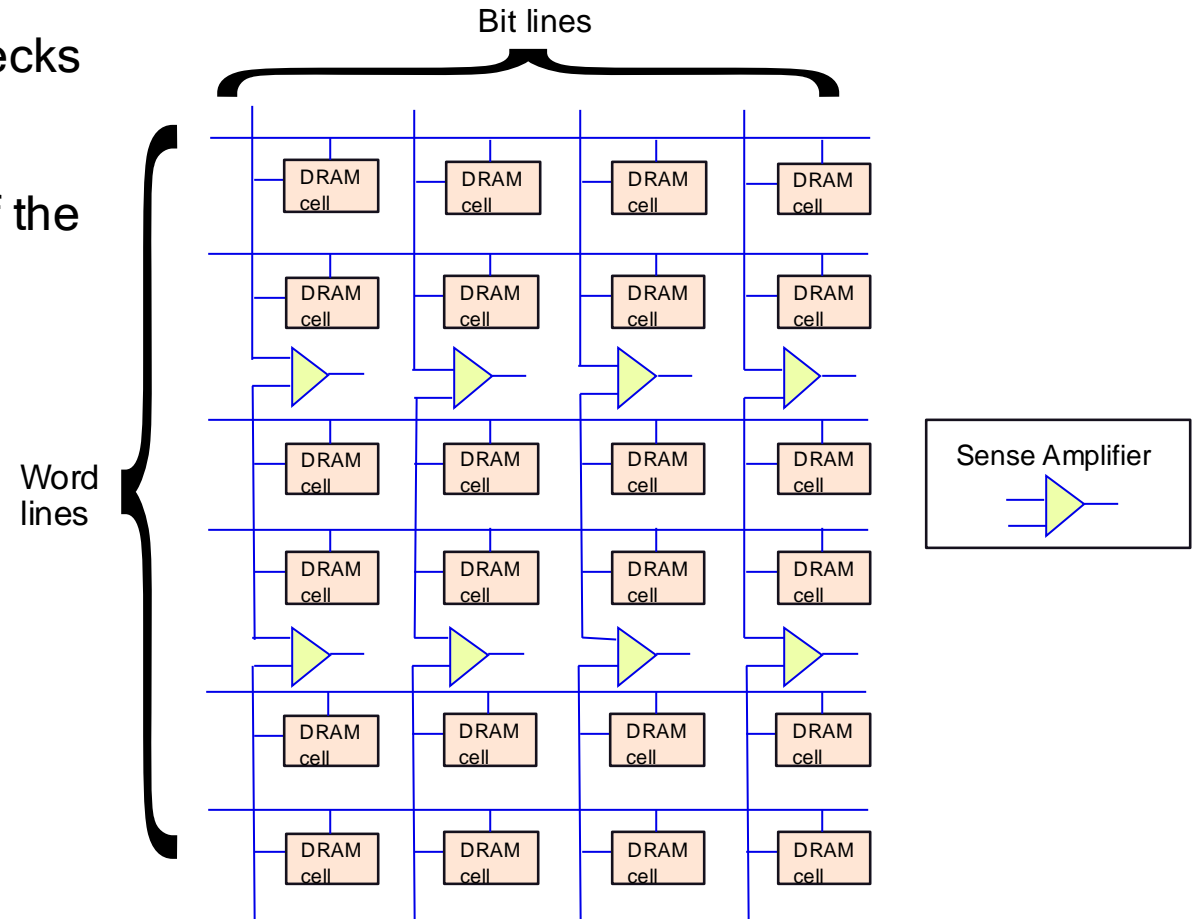
Sense Amplifier

- Sense the value
- Strobe the value
- Precharge the bit line



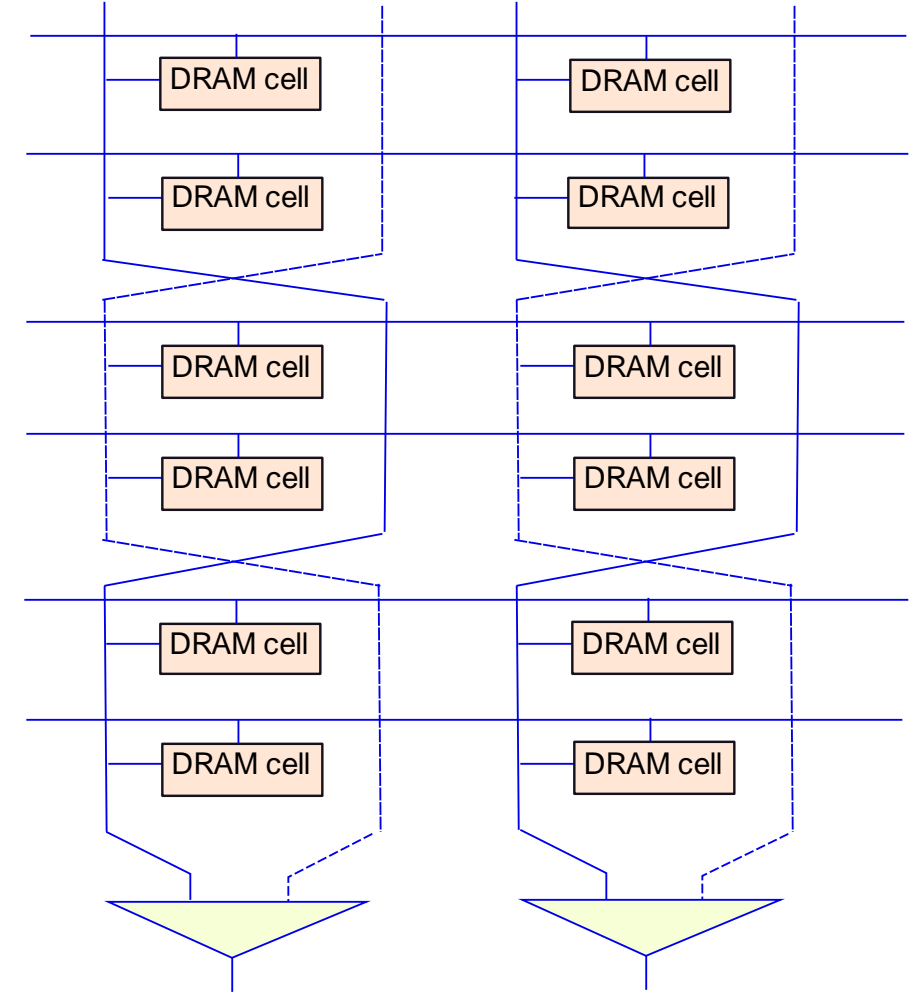
Open Bit Line Array Architecture

- **Problem** - Bit line is very long, hence it will have high resistance and capacitance. Now detecting the voltage change in bit line is very tricky that too we have to do with tiny cell capacitance voltage
- **Solution** - Reduce the length of the bit line
- Open bit line architecture is more noise tolerant as it checks the difference in the noise
- Since my bit line length is small, I can reduce the size of the Cell capacitor as well
- Area $\rightarrow 6F^2$



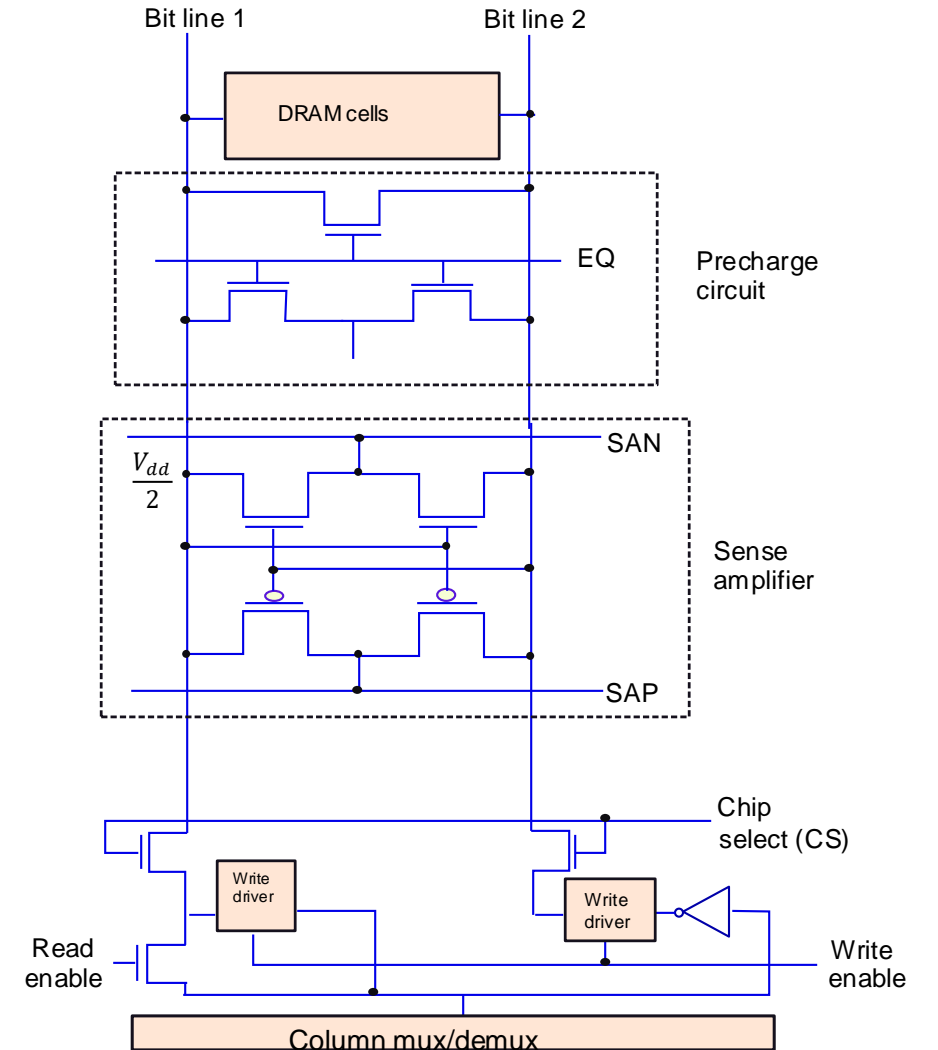
Folded Bit Line Array Architecture

- Area $\rightarrow 8F^2$
- Ease of manufacturing
- Efficiency (Read access latency)
- Storage density

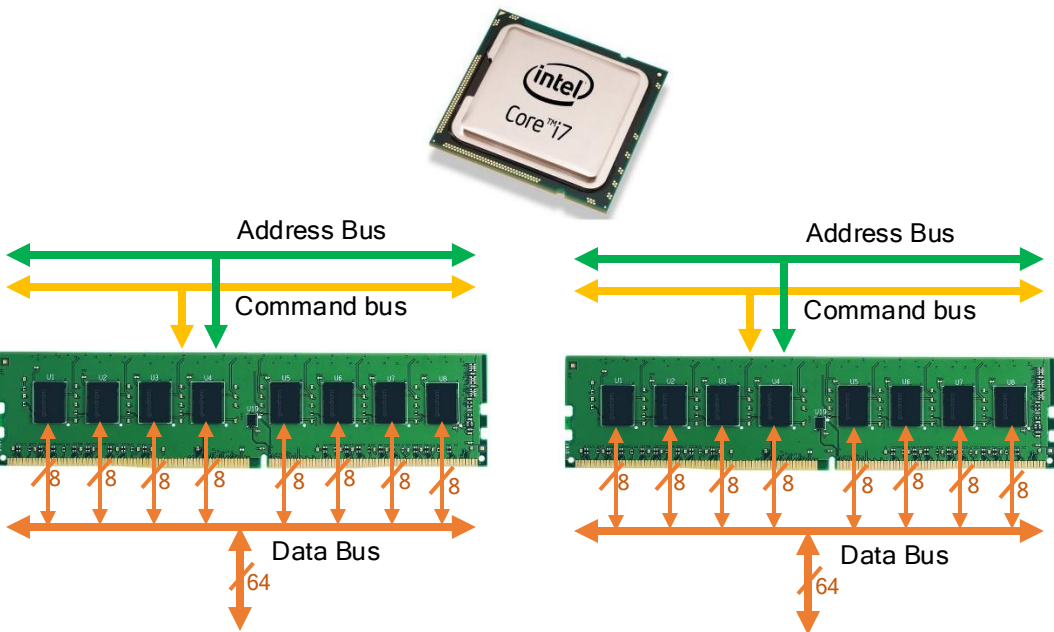


Sense Amplifier

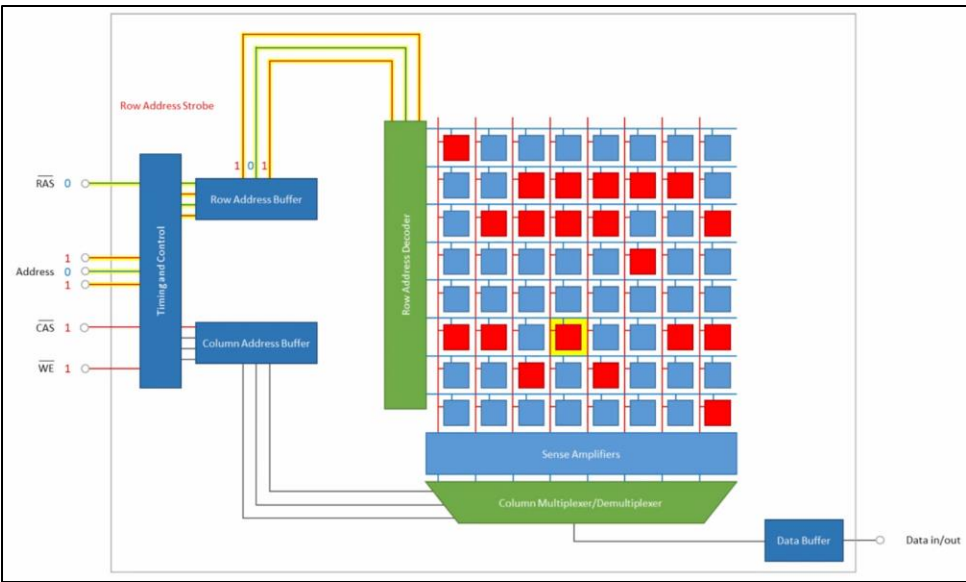
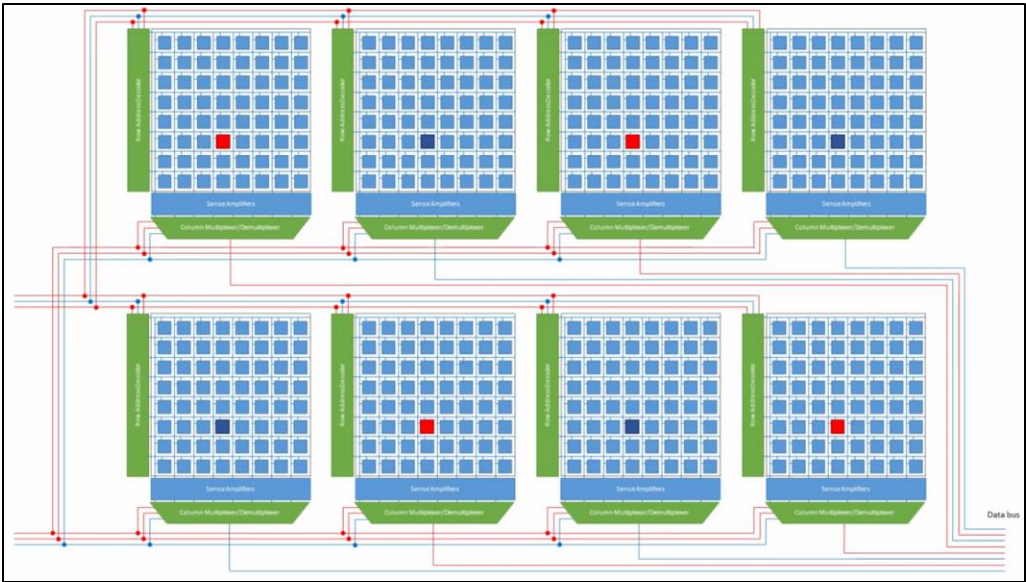
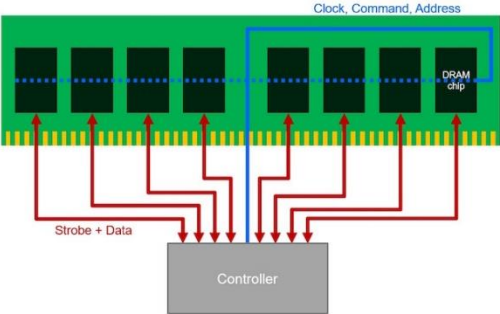
- The sense amplifier serves dual purpose



DRAM Organization



Front side of the DIMM is called Rank0
Back side of the DIMM is called Rank1



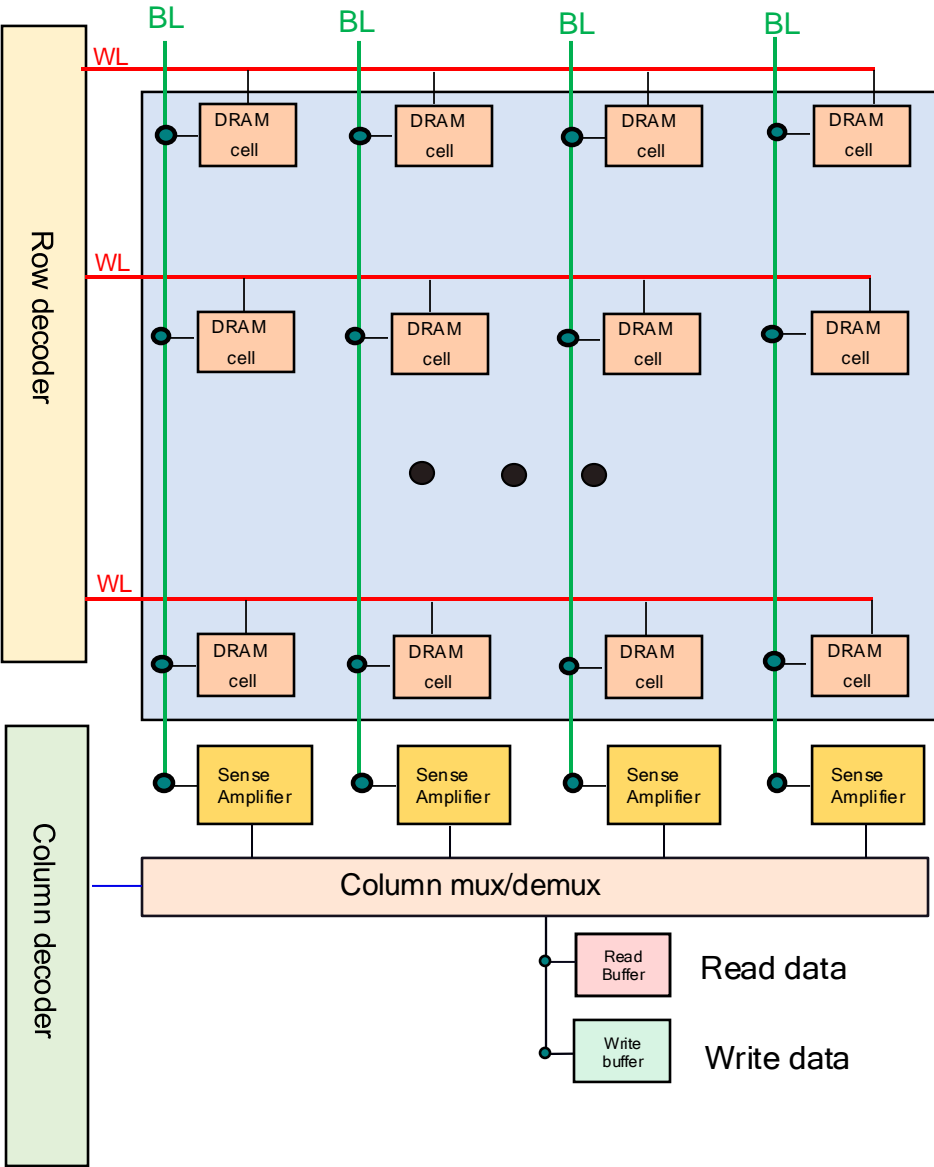
DDR Memory Comparisons

	SDRAM	DDR1	DDR2	DDR3
Performance	63-133MT/s	200-400MT/s	400-800MT/s	800-1600MT/s
V_{DDQ}	3.3V	2.5V	1.8V	1.5V
V_{TT}	NA	$\frac{1}{2} V_{DDQ}$	$\frac{1}{2} V_{DDQ}$	$\frac{1}{2} V_{DDQ}$
Organization	x4, x8, x16	x4, x8, x16	x4, x8, x16	x4, x8, x16
Density	16Mb-512Mb	64Mb-2Gb	256Mb-4Gb	512Mb-8Gb
Number of banks	4	4	4 (256Mb-512Mb) 8 (1Gb-4Gb)	8
Prefetch	1	2	4	8
Burst length	1,2,4,8,page	2, 4, 8	4, 8	8 (chop 4)
Clock	Single ended	Differential	Differential	Differential
Strobes	NA	Single ended	SE or Differential	Differential

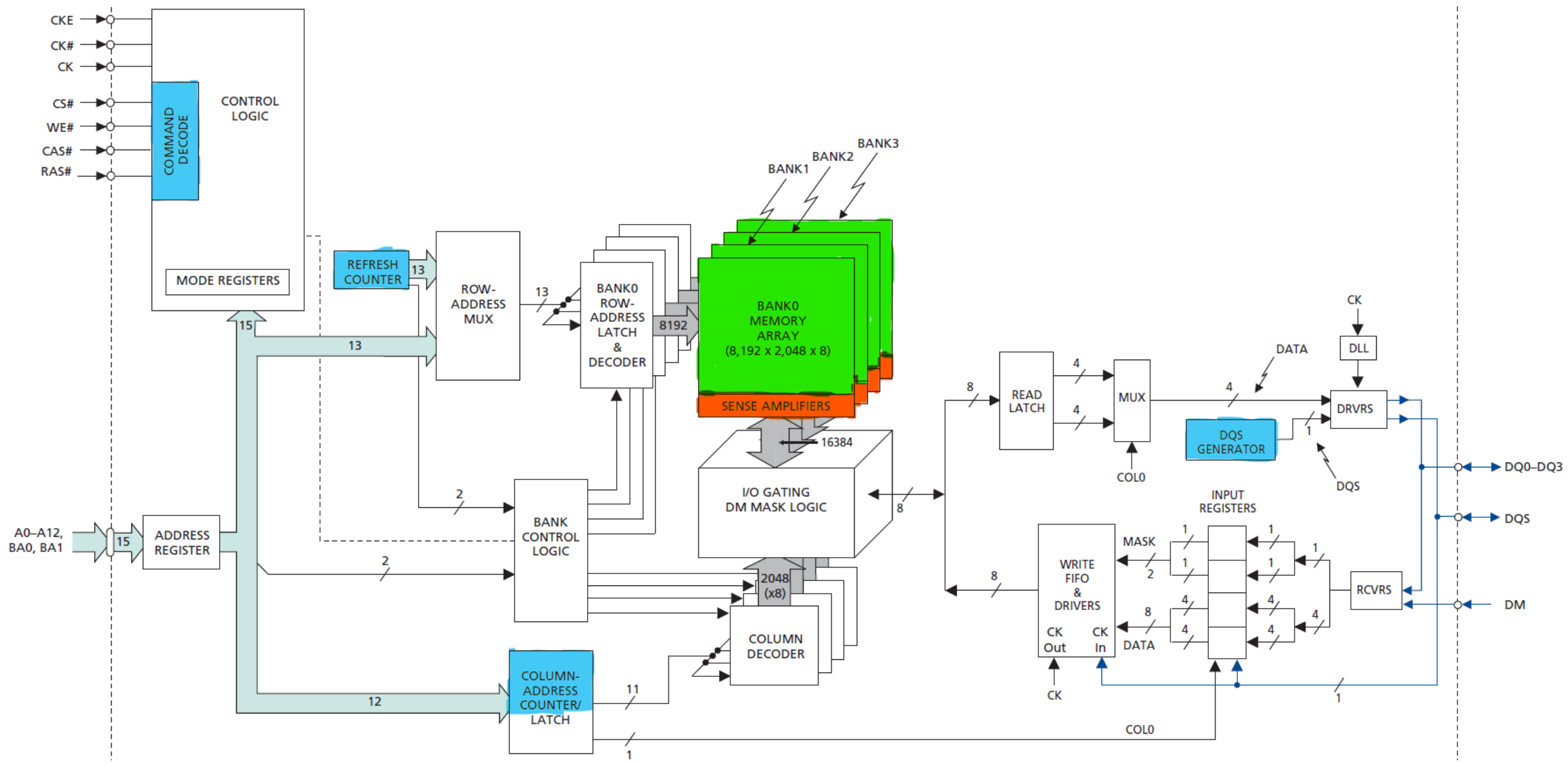
Reading data sheet

- 32Meg x 4 x 4 banks
 - Density x Data width x banks

DDR Block Diagram



DDR Block Diagram



DDR Memory Signals

[illegible]

LPDDR

LPDDR Acronyms

- tRP → Row Precharge Time
- tWR → Write Recovery Time
- tRCD → Row to Column Delay
- tMRD → Mode Register Delay
- tRFC → Refresh cycle time
- tCK → Clock cycle time
- tREFI → Refresh Interval

1	VDD and VDDQ Ramp: CKE must be held high
2	Apply stable clocks
3	Wait at least 200 μ s with NOP or DESELECT on command bus
4	PRECHARGE ALL
5	Assert NOP or DESELECT for t _{RP} time
6	Issue two AUTOREFRESH commands each followed by NOP or DESELECT commands for t _{RFC} time
7	Configure Mode Register
8	Assert NOP or DESELECT for t _{MRD} time
9	Configure Extended Mode Register
10	Assert NOP or DESELECT for t _{MRD} time
11	LPDDR SDRAM is ready for any valid command

LPDDR Features

- Double data rate architecture - Two transfers per clock cycle
- Differential clock inputs
- 4 internal banks for concurrent operation
- Commands are entered each positive edge of the CK
- Bidirectional DQS signal used to capture the data at receiver end
 - Data and data mask are sampled at both the edges of the DQS
 - DQS is edge aligned with data for READ and center aligned with data for WRITE
 - Input data is registered at both the edges of the DQS
 - Output data is referenced to both edges of DQS, as well as to both edges of CK

LPDDR Basics

- LPDDR architecture is an $2n$ prefetch architecture
- LPDDR is designed to transfer 2 words per clock cycle (Double Data Rate)
- Single read/write data consists of,
 - 1 clock cycle to move data from core
 - $\frac{1}{2}$ clock cycle to move data from I/O pin
- During READ operation DQS is asserted by the DRAM and during write operation DQS signal is asserted by the Memory Controller
- At crossing points of CK and CK#, when CK is going high and CK# is going low is termed as positive edge of the CK
 - Commands (Address and control signals) are registered during each positive edge of the CK
 - All the DRAM internal clocks are derived from CK
- Auto Precharge can be initiated at the end READ/WRITE transactions
- The pipelined multibank architecture of the LPDDR allows the operations to be executed in parallel
 - Provides high effective bandwidth by hiding row precharge and activation times
- Packages
 - Single die - 1CS, 1CKE
 - Dual-die - 2CS, 2CKE
- LPDDR comes with x16, x32 variants only

LPDDR signals

- DM is applicable only for write transactions with x16 and x32 variants
 - X16 - LDM and UDM
 - X32 - DM0, DM1, DM2 and DM3
- DQS is used to capture the data from DQ lines
 - X16 - LDQS and UDQS
 - X32 - DQS0, DQS1, DQS2 and DQS3
- VDD - Core power
- VDDQ - I/O power
- TQ - Asynchronous LV-CMOS output
 - High - when device temperature equals or exceeds 85°C
 - Low - when device temperature less than 85°C

LPDDR Burst transactions

- Read and Write accesses to the LPDDR is burst oriented
 - Accesses start at a selected location and will continue for the programmed number of locations in programmed sequence
- Programmable Read/Write burst lengths of 2, 4, 8 or 16

LPDDR Low power features

- Auto refresh mode is provided, along with power saving power down mode
- Self refresh mode may have Temperature Compensated Self Refresh (TCSR) and Partial Array Self Refresh (PASR) options, which allows users to achieve additional power saving
 - TCSR and PASR options can be programmed via extended mode register
- All inputs are LV-CMOS compatible
- VDD and VDDQ supply of 1.8V
- Power down
 - Looks like same of self refresh entry
 - 2 possible power down
 - All banks are idle - Means no row is open → Precharge power down
 - Banks are active - Means row is open → Active power down
- Deep power down
 - Deep power down is entered with burst terminate command except that CKE is registered low
 - All the data in DRAM is lost
 - ToDo - Understand entry and exit sequence
- Clock stop
 - Stopping clock during idle periods are effective way to reduce the power consumption
 - ToDo - Understand entry and exit sequence

LPDDR Refresh requirements

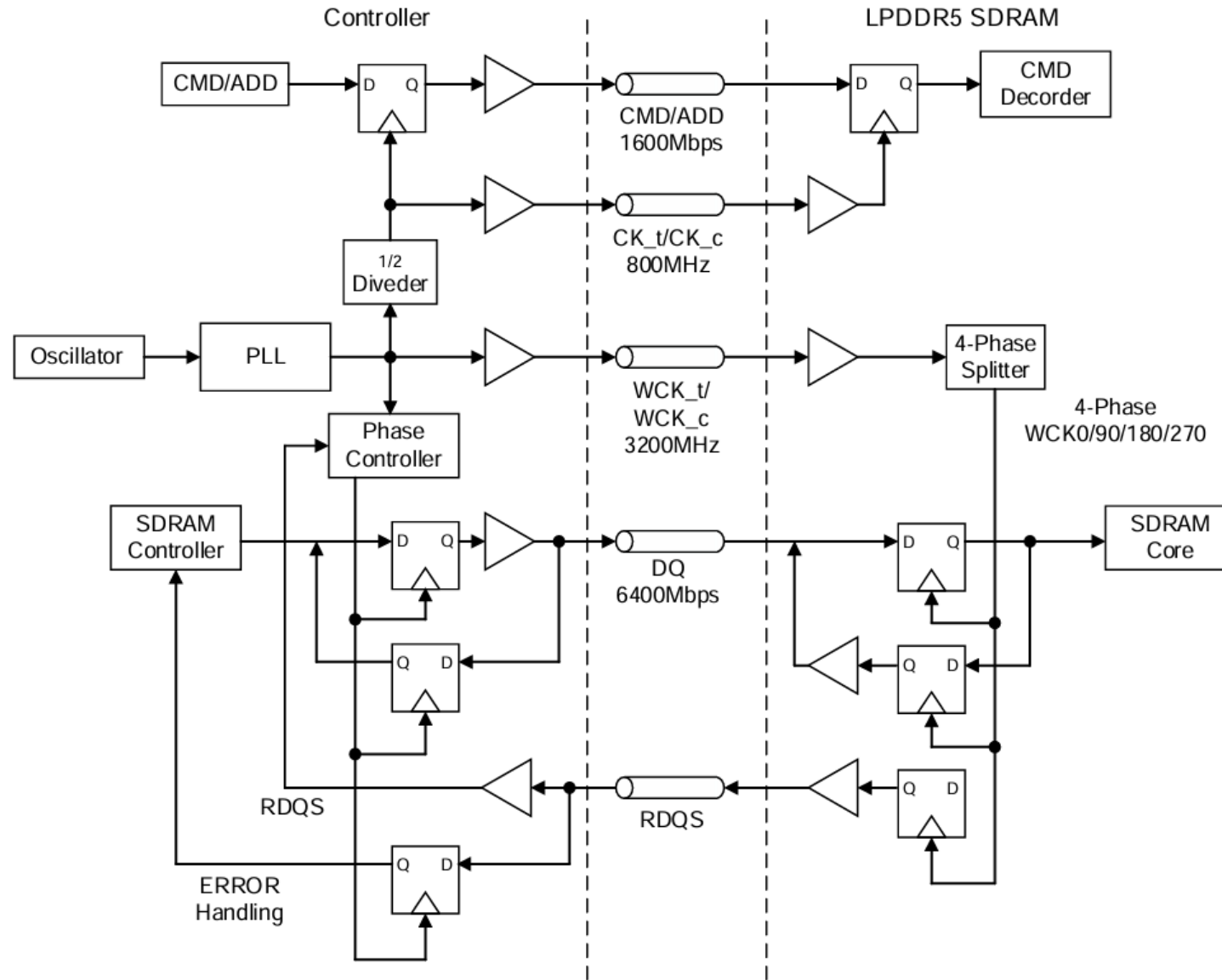
- SDRAM must require to refresh every row at each 64ms
- Accomplished by explicit AUTO REFRESH command or internally timed event in SELF REFRESH mode
- Self refresh entry
 - Register SELF REFRESH command (CKE brought LOW)
 - User may halt the external clock after the one clock of SELF REFRESH command is triggered (CKE brought LOW)
 - The minimum time the device must be in Self refresh mode is defined as tRFC (Refresh Cycle Time)
- Self refresh exit
 - CK must be stable before CKE brought high
 - Wait until tXSR (Self refresh exit time) to allow the completion of any internal refresh in progress

LPDDR5

WCK2CK Synchronization

- LPDDR5 will be able to detect or reset WCK2CK alignment state by the process called WCK2CK synchronization

Clocking Architecture



Command Truth Table

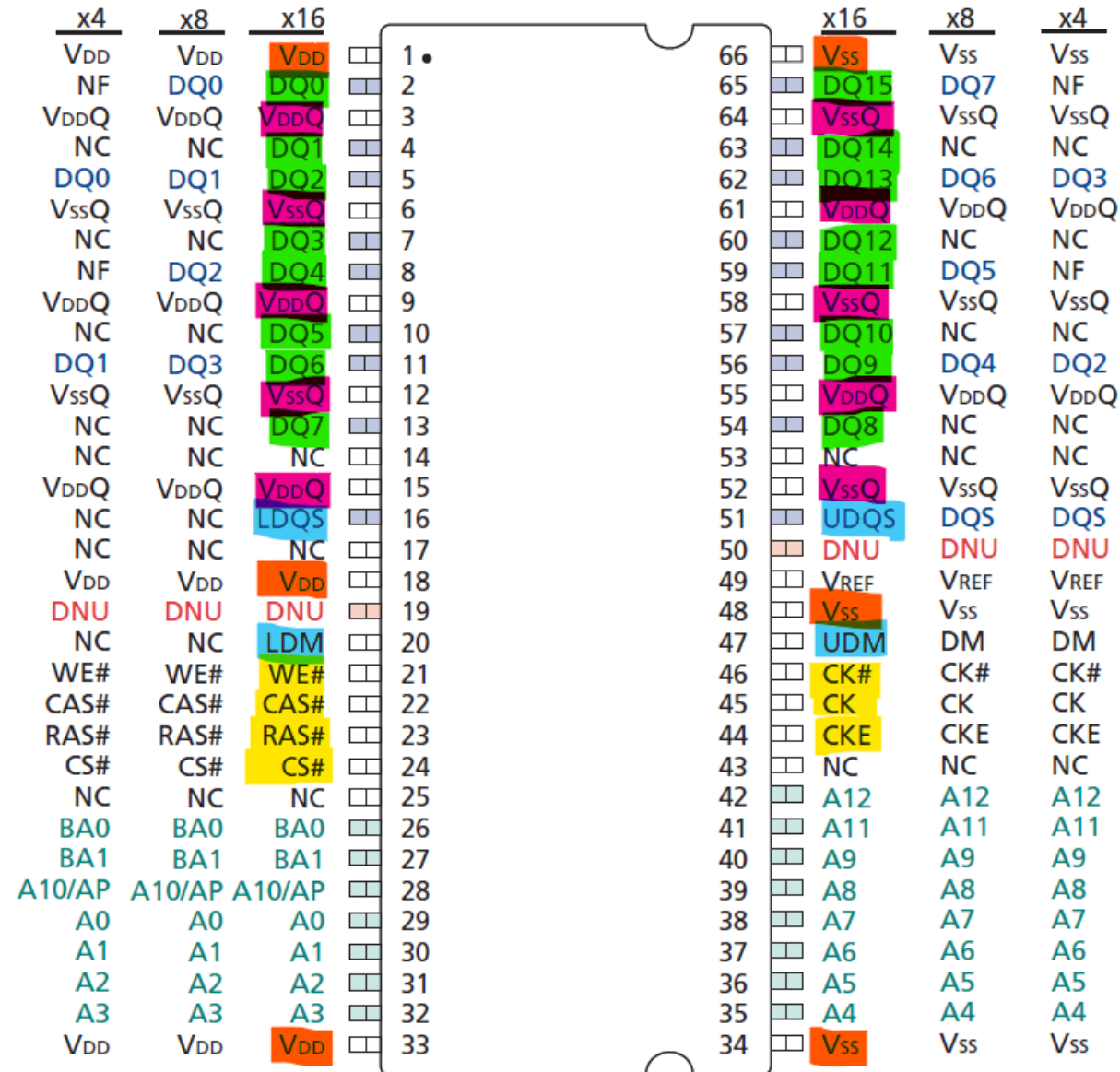
SDRAM Command	Bank ORG	SDR	DDR							CK_t
		CS	CA0	CA1	CA2	CA3	CA4	CA5	CA6	
READ (RD16 or RD)	ANY	H	H	L	L	C0	C3	C4	C5	R1
	BG	X	BA0	BA1	BG0	BG1	C1	C2	AP	F1
	16B		BA0	BA1	BA2	BA3				
	8B		BA0	BA1	BA2	V				
READ (RD32)	BG/16B	H	H	L	H	C0	C3	C4	C5	R1
	BG	X	BA0	BA1	BG0	BG1	C1	C2	AP	F1
	16B		BA0	BA1	BA2	BA3				
MASK WRITE (MWR)	ANY	H	L	H	L	C0	C3	C4	C5	R1
	BG	X	BA0	BA1	BG0	BG1	C1	C2	AP	F1
	16B		BA0	BA1	BA2	BA3				
	8B		BA0	BA1	BA2	V				
WRITE (WR16 or WR)	ANY	H	L	H	H	C0	C3	C4	C5	R1
	BG	X	BA0	BA1	BG0	BG1	C1	C2	AP	F1
	16B		BA0	BA1	BA2	BA3				
	8B		BA0	BA1	BA2	V				
WRITE32 (WR32)	ANY	H	L	L	H	L	C3	C4	C5	R1
	BG	X	BA0	BA1	BG0	BG1	C1	C2	AP	F1
	16B		BA0	BA1	BA2	BA3				
	8B		BA0	BA1	BA2	V				

Command Truth Table

SDRAM Command	Bank ORG	SDR	DDR							CK_t
		CS	CA0	CA1	CA2	CA3	CA4	CA5	CA6	
SELF REFRESH ENTRY (SFE)	ANY	H	L	L	L	H	L	H	H	R1
		X	V	V	V	V	V	DSM	PD	F1
SELF REFRESH EXIT (SFX)	ANY	H	L	L	L	H	L	H	L	R1
		X	V	V	V	V	V	V	V	F1
MODE REGISTER WRITE - I (MRW - I)	ANY	H	L	L	L	H	H	L	H	R1
		X	MA0	MA1	MA2	MA3	MA4	MA5	MA6	F1
MODE REGISTER WRITE - II (MRW-II)	ANY	H	L	L	L	H	L	L	OP7	R1
		X	OP0	OP1	OP2	OP3	OP4	OP5	OP6	F1
MODE REGISTER READ (MRR)	ANY	H	L	L	L	H	H	L	L	R1
		X	MA0	MA1	MA2	MA3	MA4	MA5	MA6	F1
WRITE FIFO (WFF)	ANY	H	L	L	L	L	L	H	H	R1
		X	L	L	L	L	L	L	L	F1
READ FIFO (RFF)	ANY	H	L	L	L	L	L	H	L	R1
		X	L	L	L	L	L	L	L	F1
READ DQ CALIBRATION (RDC)	ANY	H	L	L	L	L	H	L	H	R1
		X	L	L	L	L	L	L	L	F1
CAS	ANY	H	L	L	H	H	WS_WR	WS_RD	WS_FS	R1
		X	DC0	DC1	DC2	DC3	WRX	WXSA	WXSB/B3	F1
MULTI-PURPOSE COMMAND (MPC)	ANY	H	L	L	L	L	H	H	OP7	R1
		X	OP0	OP1	OP2	OP3	OP4	OP5	OP6	F1

DDR

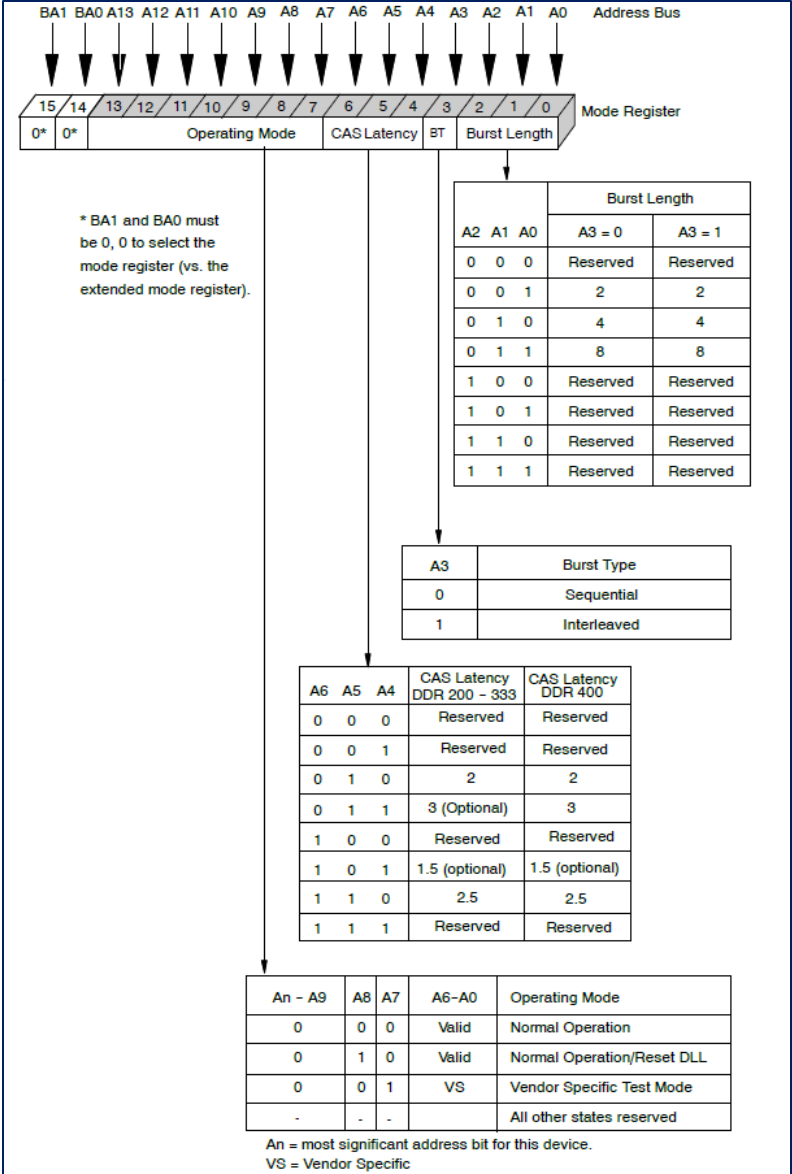
DDR Pin Diagram



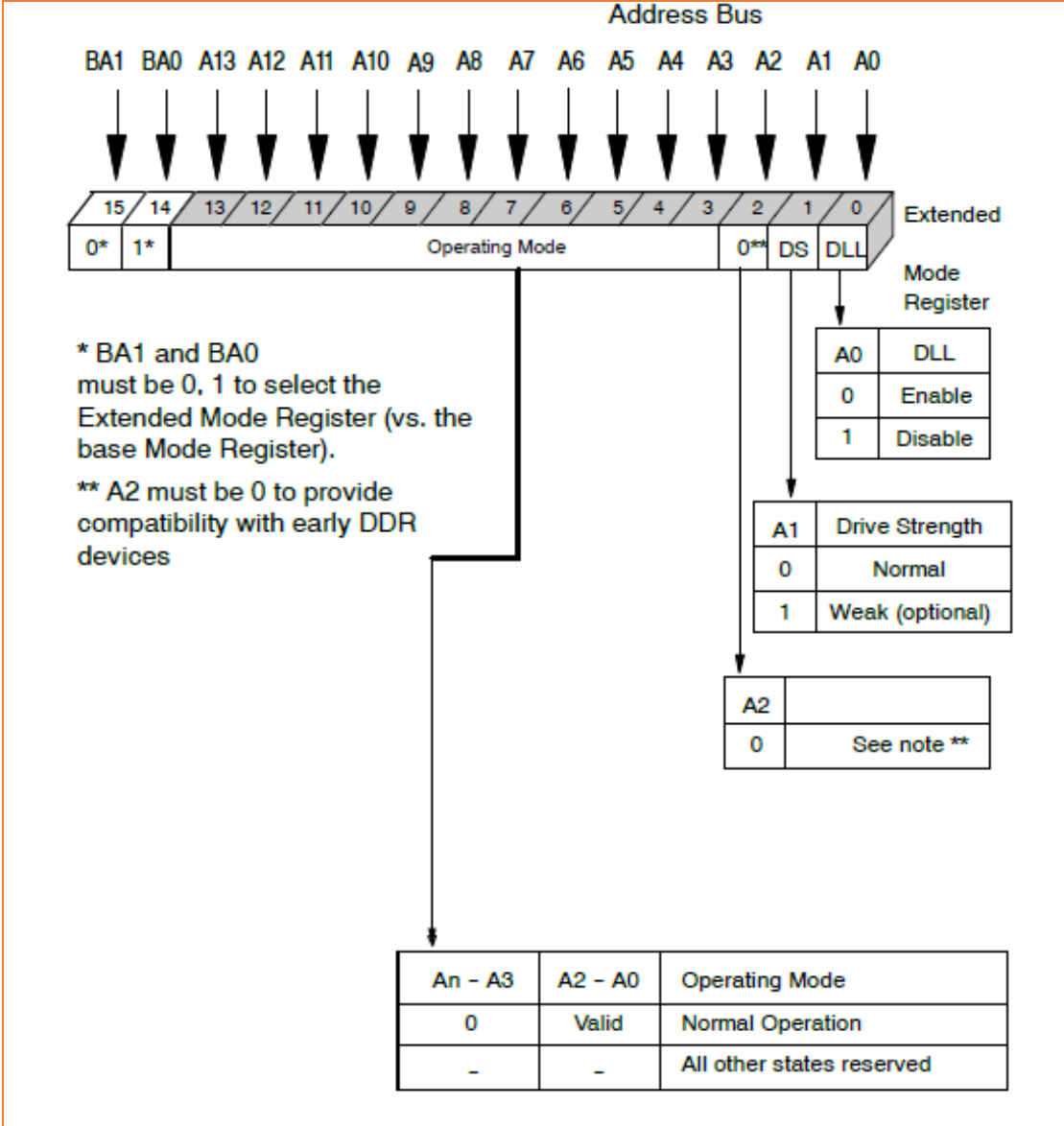
DDR Truth Table

Command	CS#	RAS#	CAS#	WE#	Address	Comments
DESELECT (NOP)						
No Operation (NOP)						
ACTIVE					Bank/Row	
READ					Bank/Column	
WRITE					Bank/Column	
BURST TERMINATE						
PRECHARGE					Code	
SELF REFRESH						
MODE REGISTER SET					Opcode	

DDR Mode and Extended Register



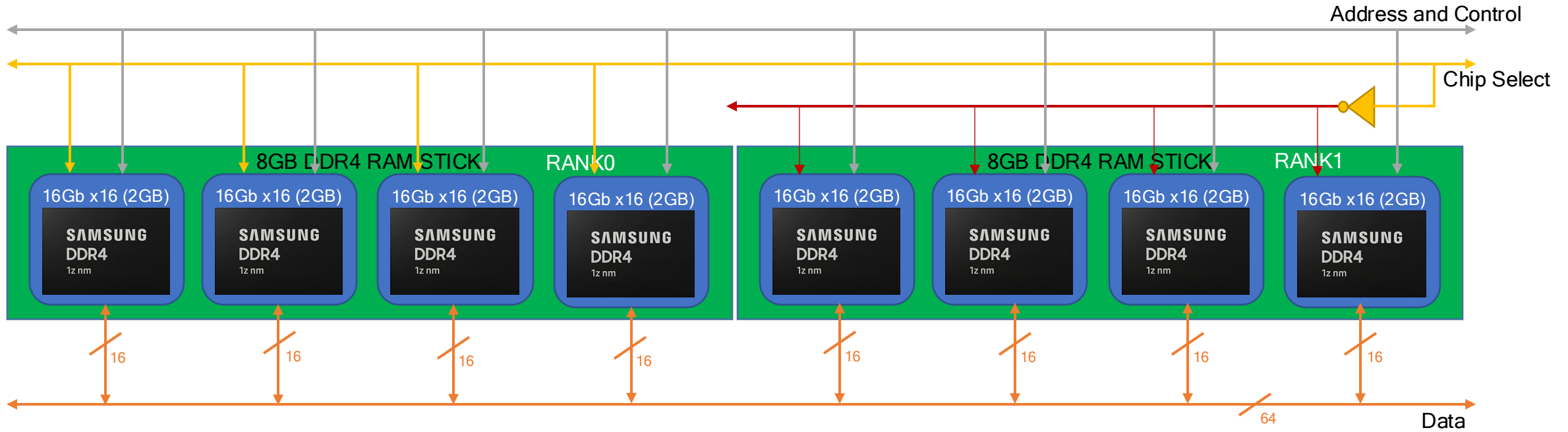
Mode Register



Extended Mode Register

DDR2

16GB DDR with 2 Rank configuration



16GB DDR with 1 Rank configuration

